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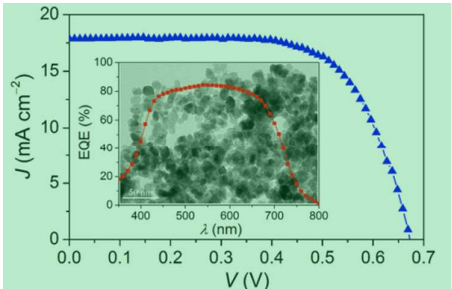
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TOC



The dye-sensitized solar cell based on the Zn-doped SnO₂ nanocrystal photoanode has achieved a remarkable power conversion efficiency of 8.23%.

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PAPER

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Zinc-doped SnO₂ nanocrystals as photoanode materials for highly efficient dye-sensitized solar cells

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Zn-doped SnO₂ nanocrystals were successfully synthesized by a simple hydrothermal method. It is found that Zn doping into SnO₂ can induce a negative shift in the flat-band potential (V_{FB}) and increase the isoelectric point. As a result, the dye-sensitized solar cells (DSCs) based on Zn-doped SnO₂ nanocrystal photoanodes exhibit longer electron lifetimes and larger dye loading compared to the undoped SnO₂ based DSC. The overall power conversion efficiency (η) of the optimized Zn-doped SnO₂ based DSC reaches 4.18% and increases to 7.70% after the TiCl₄ treatment. More importantly, a remarkable η of 8.23% is achieved for the DSC based on a high-quality double-layer SnO₂ photoanode with the TiCl₄ treatment, to our best knowledge, which is so far the best reported efficiency for DSCs based on SnO₂ photoanodes.

1. Introduction

The growing demand for renewable energy sources has led to considerable development in many areas related to the research and manufacture of solar cells. Over the past two decades, dye-sensitized solar cells (DSCs) have attracted tremendous interest as a promising candidate for future green energy due to their low production cost and efficient photovoltaic performance.^{1,2} As a crucial component of a DSC, the wide-gap semiconductor metal oxide plays two significant roles as a carrier for dye molecules and a transporter for the photoinjected electrons. Up to now, more than 12% power conversion efficiency has been reported for DSCs based on mesoporous TiO₂ nanocrystalline photoelectrodes.³ Semiconductor metal oxides other than TiO₂, such as ZnO, SnO₂, and Nb₂O₅, have also been investigated as potential alternatives to TiO₂.⁴⁻¹⁰ Among them, SnO₂ possesses a higher electron mobility ($\sim 100\text{--}200\text{ cm}^2\text{ V}^{-1}\text{ S}^{-1}$)^{11,12} than TiO₂ ($< 1\text{ cm}^2\text{ V}^{-1}\text{ S}^{-1}$)¹³, suggesting a faster diffusion transport of photoinjected electrons to a transparent conductive oxide current collector. Moreover, in comparison with TiO₂, SnO₂ have a larger band gap (3.6 eV), which would create fewer oxidative holes in the valence band, resulting in a low sensitivity of UV degradation and enhancement of the long-term stability of DSCs.¹⁴

However, the overall power conversion efficiencies (η) of SnO₂ based DSCs reported so far are much less than those of TiO₂ based DSCs. The inferior photovoltaic performances of DSCs with SnO₂ photoanodes are ascribed to the following: (1) a $\sim 300\text{ mV}$ positive shift of the conduction band edge of SnO₂ in contrast to that of TiO₂, leading to a faster electron recombination of photoinjected electrons with the redox electrolyte and a lower of open circuit voltage (V_{oc});¹⁵ (2) a lower isoelectric point (iep, at

pH 4–5) than anatase TiO₂ (iep, at pH 6–7),⁶ resulting in less adsorption of the dye with acidic carboxyl groups. To solve these issues, the general strategy has been carried out to enhance the photovoltaic performance of SnO₂ based DSCs by coating on SnO₂ photoanodes with a thin shell layer of semiconducting or isolating metal oxide, such as TiO₂, ZnO, MgO, and Al₂O₃.^{6,14-21} It has been found that these thin shell layers can inhibit interfacial electron recombination and enhance the cell performance. Kuang et al. have achieved a highly efficient DSC with a power conversion efficiency of 6.8% based on the TiO₂ coated hierarchical SnO₂ octahedra.²² Recently, Lee and coworker have reported that Zn doping in ordered mesoporous SnO₂ with a 2D hexagonal structure can tune the sub-band-edge surface states and improve the power conversion efficiency of ordered mesoporous SnO₂ based DSCs from 0.81 to 3.73%.²³ Shortly after that, Dou et al. have reported the power conversion efficiency for the DSC based on Zn-doped SnO₂ nanoflowers with high electron mobility can reach 3.0% and increase to 6.78% after TiO₂ coating.²⁴ Therefore, incorporating both the advantages of Zn-doped SnO₂ and TiO₂-coated SnO₂ is a good choice for improving the photovoltaic performance of SnO₂ based DSCs.

To date, the photoanodes are all comprised of nanocrystalline particles for high-efficiency DSCs due to their large surface area.^{3,25-32} However, the DSCs based on Zn-doped SnO₂ nanocrystal photoanodes have not been investigated. Herein, we present the synthesis of Zn-doped SnO₂ nanocrystals by a simple hydrothermal method and their use as photoanodes in DSCs. It is found that the Zn doping can suppress the interfacial electron recombination and enhance dye-uptake capabilities. Consequently, the performance of the Zn-doped SnO₂ based DSC has a more than three-fold improvement compared to that of the

undoped SnO₂ based DSC. Moreover, after the TiCl₄ post treatment of the photoanode, the Zn-doped SnO₂ based DSC exhibits an impressive power conversion efficiency of 7.70%. Finally, by employing a high-quality double-layer SnO₂ film with the TiCl₄ post treatment, the performance of the Zn-doped SnO₂ based DSC is further enhanced, achieving a remarkable efficiency of 8.23%. To the best of our knowledge, for the first time the DSC based on the SnO₂ photoanode exceeds the power conversion efficiency of 8%.

2. Experimental

2.1 Materials

Tin (IV) chloride pentahydrate (SnCl₄·5H₂O), zinc acetate dihydrate (Zn(CH₃COO)₂·2H₂O), ammonium hydroxide (NH₄OH), potassium stannate trihydrate (K₂SnO₃·3H₂O), urea, titanium (IV) chloride (TiCl₄), ethanol and acetone were purchased from Sinopharm Chemical Reagent Co., Ltd. 1,3-dimethylimidazolium (DMII), lithium iodide (LiI), iodine (I₂), tert-butylpyridine (TBP), guanidinium thiocyanate (GNCS), acetonitrile, valeronitrile, tert-butanol, ethyl cellulose powders (nos. 46070 and 46080), α-terpineol, chenodeoxycholic acid were purchased from Sigma-Aldrich. The C106 dye was synthesized according to the literature method.²⁸

2.2 Synthesis of undoped and Zn-doped SnO₂ nanocrystals

The undoped and Zn-doped SnO₂ nanocrystals were synthesized by a hydrothermal method. Typically, a mixture of 20 mL of deionized water containing 0.6 M of SnCl₄·5H₂O and a predetermined amount of Zn(CH₃COO)₂·2H₂O (0, 1, 2 and 4 at.% atom ratio to SnCl₄·5H₂O) was slowly added to the ammonium hydroxide solution that was prepared by mixing 16 mL of NH₄OH with 24 mL of deionized water. The mixture was stirred for 2 h. The solution was transferred to a Teflon-lined stainless steel autoclave and heated at 200 °C for 12 h. After naturally cooling down to the room temperature, the white products were centrifuged, washed with deionized water and ethanol for several times, and finally dried at 60 °C.

2.3 Synthesis of SnO₂ spheres

The SnO₂ spheres were prepared using a modified hydrothermal method in an ethanol–water mixed solvent.³³ In a typical experiment, 19 mM K₂SnO₃·3H₂O and 0.1 M urea were added to a mixed solution of 12 mL ethanol and 18 mL deionized water. After mild magnetic stirring for 10 min, the solution was then transferred to a 50 mL Teflon-lined stainless steel autoclave and heated at 150 °C for 20 h. After naturally cooling down to the room temperature, the obtained products were centrifuged, washed with deionized water and ethanol for several times, and finally dried at 60 °C.

2.4 Electrode preparation and device fabrication

The typical preparation of the SnO₂ paste is according to the standard procedure for the DSC electrode fabrication.³⁴ The photoanode was made by screen printing the pastes onto a pre-cleaned fluorine-doped tin oxide (FTO) conducting glass (Nippon Sheet Glass, Solar, 4-mm-thick) with an active area of ~0.283 cm² and thickness of ~8.5 μm. The TiCl₄ treatment for the SnO₂ nanoparticle films was performed by immersing the SnO₂

photoanodes into a 40 mM TiCl₄ aqueous solution at 70 °C for 30 min. After that, the photoanodes were washed with deionized water and ethanol to remove residual TiCl₄, and then sintered at 500 °C in air for 30 min. Finally, the photoanodes was stained by immersing it into a dye solution containing C106 dye (150 μM) and chenodeoxycholic acid (2 mM) in the mixture of acetonitrile and tert-butanol (volume ratio: 1/1) for 20 h. The dye-coated SnO₂ electrode was subsequently washed with acetonitrile, and then assembled with a thermally platinized FTO positive electrode. The two active electrodes were separated with a 25-μm-thick Surlyn (DuPont) hot-melt gasket and sealed up by heating. The internal space was filled with electrolytes using a vacuum back filling system. The electrolyte-injecting hole on the counter electrode made with a sand-blasting drill, was sealed with a Surlyn sheet and a thin glass cover by heating. The electrolyte is composed of 1.0 M DMII, 50 mM LiI, 30 mM I₂, 1.0 M TBP, and 0.1 M GNCS in the 85/15 (volume ratio) mixture of acetonitrile and valeronitrile.

2.5 Characterization

X-ray power diffraction (XRD) analysis was conducted on a Rigaku D/max-2500 X-ray diffractometer with Cu Kα radiation (λ=1.5418 Å). Transmission electron microscope (TEM) and high-resolution TEM (HRTEM) observations were carried out with a JEOL JEM-2100 microscope operated at 200 KV. Field emission scanning electron microscopic (FESEM) images were performed on a JEOL JEM-6700F microscope operating at 5 KV. X-ray photoelectron spectroscopy (XPS) measurements were obtained from a PHI 5700 ESCA system. The Brunauer-Emmett-Teller (BET) surface area was determined by N₂ adsorption-desorption at 77 K using a BELSORP-max surface area analyzer. UV-vis absorbance spectra were recorded by Shimadzu 3600 UV-vis Spectrophotometers. The dye loading capability was estimated by desorbing the dye into a ethanol–water mixed solution (volume ratio: 1/1) containing 0.1 M NaOH and subsequently measuring the absorption spectrum using a Shimadzu 3600 UV-vis spectrophotometer. The flat-band potential (*V*_{FB}) was calculated from the Mott-Schottky plots. The standard three-electrode configuration was used, with a platinum wire as the counter electrode and Ag/AgCl electrode as the reference.

2.6 Photovoltaic measurements

A Keithley 2400 source meter and a Zolix Omni-2300 monochromator equipped with a 500 W xenon lamp were used to measure external quantum efficiency (EQE) spectra, with a wavelength sampling interval of 10 nm and a current sampling time of 2 s under the full computer control. A Hamamatsu S1337-1010BQ silicon diode used for EQE measurements was calibrated in National Institute of Metrology, China. A model LS1000-4S-AM1.5G-1000W solar simulator (Solar Light Company, USA) in combination with a metal mesh was employed to give an irradiance of 100 mW cm⁻². The light intensity was tested with a PMA2144 pyranometer and a calibrated PMA 2100 dose control system. Photocurrent density–voltage (*J*–*V*) characteristics were obtained by applying a bias potential to a testing cell and measuring photocurrent with a Keithley 2400 source meter under the full computer control. A metal mask with an aperture area of 0.158 cm² was covered on a testing cell during all measurements.

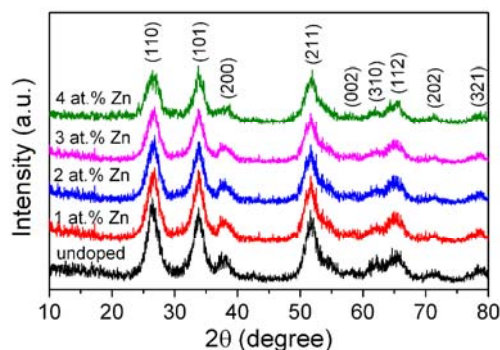


Fig. 1 XRD patterns of the undoped and Zn-doped SnO₂ nanoparticles.

An antireflection film ($\lambda < 380$ nm, ARKTOP, ASAHI Glass) is adhered to the DSC photoanode during EQE and $J-V$ measurements.

3. Results and discussion

The crystallographic structures of the undoped and Zn-doped SnO₂ nanoparticles were determined by XRD, as shown in Fig. 1. All of the diffraction peaks can be indexed to tetragonal rutile SnO₂ (JCPDS, 41-1445). No diffraction peaks from other crystalline impurities were detected. This suggests that the dopants are well-dispersed and do not cause obvious variation in the SnO₂ lattice structure. However, the intensities of the diffraction peaks gradually reduce and the full-width at half-maximum increases with an increase in the Zn-doped content, which may be attributed to a decrease in the grain size upon incorporation of Zn into the SnO₂ crystal lattice.³⁶ Further, the morphology of the undoped and 2 at.% Zn-doped SnO₂ nanoparticles was characterized by TEM, as displayed in Fig. 2a and b. It is found that some larger particles obviously reduce in the 2 at.% Zn-doped SnO₂ nanoparticles compared to the undoped SnO₂ nanoparticles. The average grain size of the 2 at.% Zn-doped SnO₂ nanoparticles is ~ 15 nm. The representative HRTEM image of the 2 at.% Zn-doped SnO₂ nanoparticles is displayed in Fig. 2c. The clear lattice fringes in the HRTEM image indicate that these nanoparticles possess a single crystal structure. The inter-planar spacing is ~ 0.334 nm, corresponding to the (110) plane of rutile SnO₂.

To obtain more concrete proof for Zn doping in SnO₂, XPS measurements were conducted on the undoped and 2 at.% Zn-doped SnO₂ nanoparticles. Fig. 3a presents a comparison of the

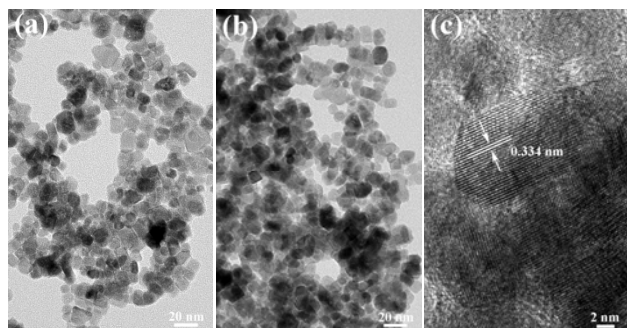


Fig. 2 (a) and (b) TEM images of undoped and 2 at.% Zn doped SnO₂ nanoparticles, respectively. (c) HRTEM image of 2 at.% Zn doped SnO₂ nanoparticles.

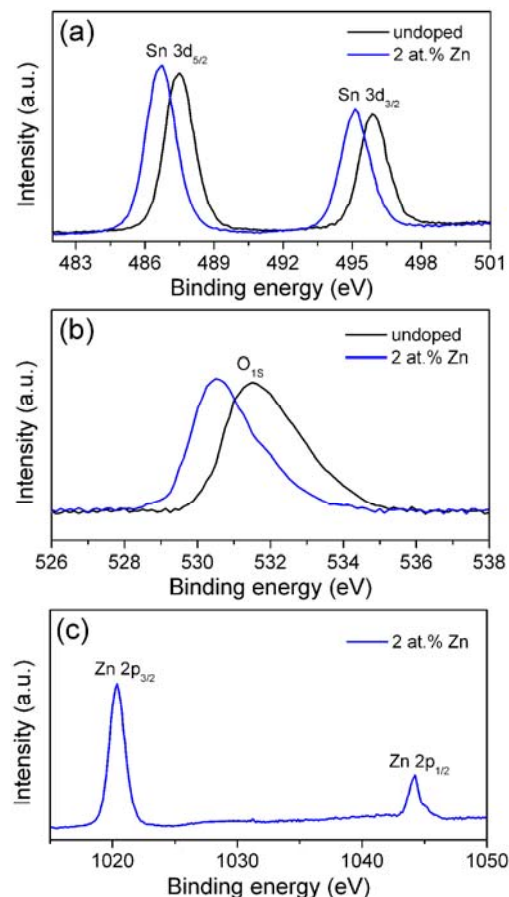


Fig. 3 XPS high-resolution spectra of undoped and Zn-doped SnO₂ nanoparticles: (a) Sn 3d, (b) O 1s, and (c) Zn 2p peaks.

Sn 3d_{5/2} and 3d_{3/2} transition peaks. Compared to the undoped SnO₂ nanoparticles, the binding energies of Sn 3d_{5/2} and 3d_{3/2} in the 2 at.% Zn-doped SnO₂ nanoparticles decrease from 487.4 to 486.6 eV and from 495.9 to 495.1 eV, respectively, which may be ascribed to oxide deficiency.³⁷ It is also found that the O 1s transition peak shifts from 531.1 to 529.8 eV upon Zn doping (Fig. 3b). The shoulder peak could be attributed to Sn-O-Zn coordination.²³ As shown in Fig. 3c, the binding energies of the Zn 2p_{3/2} and Zn 2p_{1/2} transition peaks are 1020.4 and 1044.3 eV, respectively, which confirms the presence of Zn in the doped SnO₂ nanoparticles.

The undoped and Zn-doped SnO₂ nanoparticles were used as photoanodes for DSCs. Fig. 4a shows the $J-V$ characteristics of the cells based on the undoped and Zn-doped SnO₂ photoanodes under an irradiance of 100 mW cm⁻² simulated AM1.5G sunlight and the detailed photovoltaic parameters are listed in Table 1. The short-circuit photocurrent density (J_{sc}), V_{oc} and fill factor (FF) of the cell with the undoped SnO₂ photoanode are 9.24 mA cm⁻², 335 mV and 0.428, respectively, generating a low η of 1.32%. When employing the Zn-doped SnO₂ photoanodes, the V_{oc} and J_{sc} values of the cells are significantly enhanced. A maximum η of 4.18% is obtained for the cell based on the 2 at.% Zn-doped SnO₂ photoanode.

For DSCs with a fixed redox electrolyte, it is widely recognized that the V_{oc} value is determined by the electron quasi-Fermi level in a given semiconductor material. To ascertain the

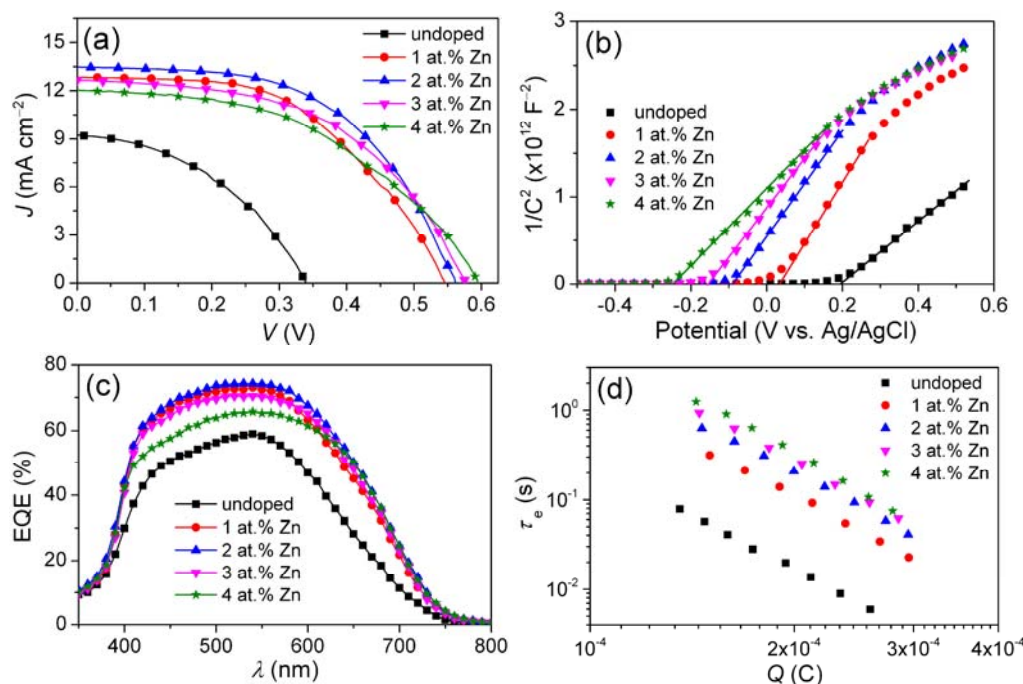


Fig. 4 (a) J - V characteristics of the undoped and Zn-doped SnO₂ based cells under an irradiance of 100 mW cm⁻² simulated AM1.5G sunlight. (b) Mott-Schottky plots of the undoped and Zn-doped SnO₂ photoanodes. (c) EQE spectra of cells based on undoped and Zn-doped SnO₂ photoanodes. (d) Plots of lifetime of photoinjected electrons in the undoped and Zn-doped SnO₂ based cells as a function of charge.

influence of the Zn doping in SnO₂ on the band edge or quasi-Fermi level, the flat-band potentials of undoped and Zn-doped SnO₂ photoanodes were achieved from the Mott-Schottky analysis.³⁸⁻⁴² The V_{FB} can be determined by the following Mott-Schottky equation⁴³

$$\frac{1}{C^2} = \left(\frac{2}{e\epsilon\epsilon_0 N_D A^2} \right) \left(V - V_{FB} - \frac{kT}{e} \right) \quad (1)$$

Where C is the differential capacitance of the space-charge region, e is the electron charge, ϵ is the dielectric constant of the semiconductor, ϵ_0 is the permittivity of vacuum, N_D denotes the donor density, A is the surface area of the electrode, V is the electrode potential, k is the Boltzman constant and T is the absolute temperature. The V_{FB} is the intercept extrapolating a straight line from the plot of the square of the space charge capacity against the applied potential. As shown in Fig. 4b, with increasing the Zn content, the V_{FB} shifts from 0.19 V for the

undoped SnO₂ photoanode to -2.50 V for the 4 at.% Zn-doped SnO₂ photoanode. The negative movement may be caused through the passivation of the sub-band-edge surface states by doping Zn into the SnO₂ framework, leading to the upward shift of the quasi-Fermi level, which may interpret the enhanced V_{oc} witnessed in the corresponding cells.^{23,41}

To comprehend the J_{sc} increment of the cells based on Zn-doped SnO₂ photoanodes, we measured the EQE spectra of these cells, as displayed Fig. 4c. The EQE data follow the same trend observed for the J_{sc} of the Zn-doped SnO₂ based cells. The EQE of the undoped SnO₂ based cell is about 59% at 540 nm. However, the incorporating Zn into SnO₂ causes an obvious increase in EQEs over the entire spectral range compared to the undoped SnO₂. The cell with the 2 at.% Zn-doped SnO₂ photoanode exhibits a maximum EQE of ~74% at 540 nm. However, when the Zn-doped content is more than 2 at.%, the cell shows a lower EQE compared to other Zn-doped SnO₂ based cells but is still higher than that of the undoped SnO₂ based cell.

Table 1. Detailed photovoltaic parameters of cells based on undoped and Zn-doped SnO₂ photoanodes.

	Zn doping (at.%)	Dye loading ($\times 10^{-7}$ mol cm ⁻²)	V_{oc} (mV)	J_{sc} (mA cm ⁻²)	FF	η (%)
no TiCl ₄ treatment	0	3.94	335	9.24	0.428	1.32
	1	4.69	542	12.85	0.522	3.64
	2	5.18	560	13.48	0.554	4.18
	3	5.59	574	12.67	0.519	3.78
	4	5.95	591	12.04	0.484	3.44
TiCl ₄ treatment	0	5.38	622	15.05	0.621	5.80
	1	6.03	665	16.48	0.669	7.43
	2	6.42	673	16.86	0.678	7.70
	3	6.77	682	16.29	0.671	7.45
	4	7.06	689	15.93	0.653	7.17

According to the above mentioned results, the negative movement of the V_{FB} may also be interpreted as a shift in the position of the conductor band edge of SnO_2 to higher potentials owing to Zn doping.⁴¹ The higher conductor band edge may

impede injection of photoelectrons and thereby degrades the EQE. In contrast to the undoped SnO_2 based cell, the enhancement in the EQE and J_{sc} for the Zn-doped SnO_2 based cells may be intimately related to the dye loading and interfacial electron recombination.⁴⁴ The adsorbed amounts of dye molecules on different photoanodes were quantified from UV-visible absorption spectra. As shown in Table 1, the Zn doping can enhance the dye-uptake capabilities of SnO_2 photoanodes. With the increase of the Zn-doped content, the adsorbed amounts of dye molecules increase from 3.94×10^{-7} to 5.95×10^{-7} mol cm^{-2} , which can be explained by measured the isoelectric points of undoped and Zn-doped SnO_2 nanoparticles. As shown in Fig. S1, compared to the isoelectric point of the undoped SnO_2 nanoparticles, the present of Zn in SnO_2 nanoparticles increases the isoelectric point from 4.3 to 5.1, which favors the attachment of dye molecules with acidic carboxyl groups.⁶ Accordingly, the Zn-doped SnO_2 based cells exhibit higher EQE and J_{sc} values.

To clarify the effect of the Zn doping in SnO_2 on the electron recombination process, we tested the dark current of the undoped and Zn-doped SnO_2 based cells. Although the dark current is not a direct measurement of the electron recombination, it is meaningful when the similar devices are compared. As displayed in Fig. S2, the dark current of the cell gradually decreases with increasing the Zn-doped content at a given potential, suggesting that the Zn doping in SnO_2 can restrain the electron recombination at the oxide/electrolyte interface. We further resorted to the transient photoelectric decay technique to measure the electron lifetime (τ_e) in the undoped and Zn-doped SnO_2 based cells. As depicted in Fig. 4d, the τ_e in the Zn-doped SnO_2 based cells is significantly higher than that in the undoped SnO_2 based cell at a certain extracted charge (Q) and increases with increasing the Zn-doped content, which is consistent with the trend observed in the dark current. The higher τ_e is attributed to the high electron mobility for the Zn-doped SnO_2 photoanodes.^{24,45,46} It is well known that the τ_e in DSCs is the key quantity that determined the recombination dynamics in the solar cells.⁴⁷ The enhancement of the τ_e in the Zn-doped SnO_2 based

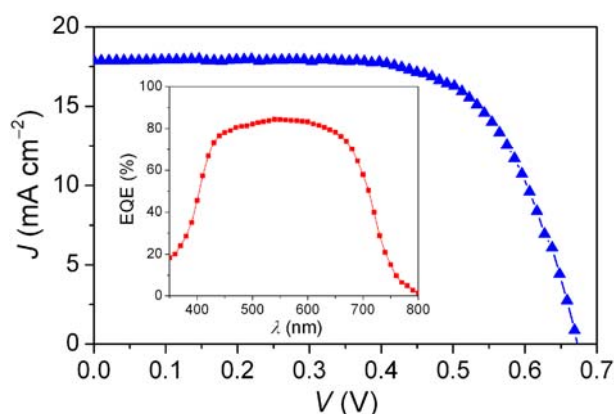


Fig. 5 J - V characteristics of the cells based on a double-layer film with the TiCl_4 treatment under an irradiance of 100 mW cm^{-2} simulated AM1.5G sunlight. The inset is its EQE spectrum

Table 2. Detailed photovoltaic parameters^a of the cell based on a double-layer film with the TiCl_4 treatment under different incident light intensities.

P_{in} (mW cm^{-2})	V_{oc} (mV)	J_{sc} (mA cm^{-2})	FF	η (%)
12.16	581	2.34	0.777	8.69
23	618	4.31	0.745	8.63
50.62	644	9.27	0.714	8.42
100	670	17.87	0.687	8.23

^a Lights at different intensities were obtained by attenuating the AM1.5G full sunlight with a set of neutral meshes. Incident power intensity: P_{in} .

cells shows the obvious inhibition of the electron recombination at the oxide/electrolyte interface. Since a low electron recombination rate is highly desirable to achieve a high charge-collection efficiency, which will also contribute to the higher EQE and J_{sc} as well as V_{oc} .

In order to enhance their performance, the undoped and Zn-doped SnO_2 photoanodes were subjected to a treatment by a solution of TiCl_4 . Fig. S3 shows the J - V characteristics of the undoped and Zn-doped SnO_2 based cells with the TiCl_4 treatment under an irradiance of 100 mW cm^{-2} simulated AM1.5G sunlight and the detailed photovoltaic parameters are also listed in Table 1. Compared to the cells without the TiCl_4 treatment, the photovoltaic parameters of the cells with the TiCl_4 treatment are significantly enhanced. The 2 at.% Zn-doped SnO_2 based cell with the TiCl_4 treatment achieves a power conversion efficiency of 7.70%. It is noteworthy that the 2 at.% Zn-doped SnO_2 based cell with the TiCl_4 treatment exhibits a higher efficiency compared to the DSCs based on SnO_2 photoanodes reported by other authors (Table S1), which is attributed to the high quality Zn-doped SnO_2 photoanode and C106 dye with high molar extinction coefficient. Moreover, it is found that the τ_e in the cells with the TiCl_4 treatment is longer at a certain extracted charge than that in the cells without the TiCl_4 treatment (Fig. S4), which is because the TiCl_4 treatment can improve the electronic connection of adjacent SnO_2 nanoparticles while slowing down the recombination processes,⁴⁸ resulting in the higher V_{oc} . After the TiCl_4 treatment, the J_{sc} enhancement of the cells is due to the increment of the dye loading (Table 1) as well as the suppression of the interfacial electron recombination.

We further employed a high-quality double-layer film via the TiCl_4 treatment, with a transparent layer based on 2 at.% Zn-doped SnO_2 nanocrystals and a scattering layer based on SnO_2 spheres (Fig. S5), to make a high-performance cell. As shown in Fig. 5, this cell has a J_{sc} of 17.87 mA cm^{-2} , a V_{oc} of 670 mV, and a FF of 0.687, yielding a remarkable efficiency of 8.23% under an irradiance of 100 mW cm^{-2} simulated AM1.5G sunlight. To our best knowledge, this is for the first time the DSC based on the SnO_2 photoanode exceeds the power conversion efficiency of 8%. The EQE spectrum of this high-efficiency cell is shown in the inset of Fig. 5. The EQEs exceed 80% in the region between 470 to 640 nm. In view that DSC is a very promising candidate for the conversion of weak light to electricity,² we also measured cell efficiencies by attenuating the AM1.5G full sunlight with a set of neutral metal meshes, and detailed cell parameters are collected in Table 2. At a light intensity of 12.16 mW cm^{-2} , this cell reaches an impressive efficiency of 8.69%.

4. Conclusions

In summary, we have successfully synthesized Zn-doped SnO₂ nanocrystals under hydrothermal conditions and investigated their performance when applied as a photoanode material in DSCs. Zn doping into SnO₂ is observed to induce a negative shift in the flat-band potential and increase the isoelectric point. Consequently, the power conversion efficiency of 4.18% is achieved for the 2 at.% Zn-doped SnO₂ based DSC, which is a more than three-fold improvement in comparison with the undoped SnO₂ based DSC. The enhancement in performance is ascribed to improve electron lifetimes and dye-uptake capabilities. Moreover, after the TiCl₄ treatment of the photoanode, the 2 at.% Zn-doped SnO₂ based DSC exhibits an impressive power conversion efficiency of 7.70%. In conjunction with a high-quality double-layer SnO₂ film with the TiCl₄ treatment, the cell performance is further enhanced, reaching a remarkable efficiency of 8.23%. This is for the first time the DSC based on the SnO₂ photoanode exceeds the power conversion efficiency of 8%. Our work demonstrates that the Zn-doped SnO₂ nanocrystals coated with TiO₂ are a promising photoanode material for boosting the performance of DSCs.

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Notes and references

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- † Electronic Supplementary Information (ESI) available: [The pH-dependent zeta-potential of the undoped and Zn-doped SnO₂ nanoparticles; J–V characteristics of the undoped and Zn-doped SnO₂ based cells measured in the dark; J–V characteristics of the undoped and Zn-doped SnO₂ based cells with the TiCl₄ treatment; Comparison of the photovoltaic performance of the DSCs based on SnO₂ photoanodes with various morphologies; Pots of lifetime of photoinjected electrons in the DSCs based on undoped and Zn-doped SnO₂ photoanodes with TiCl₄ treatment as a function of charge; FESEM image of SnO₂ spheres.] See DOI: 10.1039/b000000x/
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